Spin ltering through ferrom agnetic B M nO₃ tunnel barriers

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We report on experiments of spin litering through ultra-thin single-crystal layers of the insulating and ferror agnetic oxide B M nO₃ (BM O). The spin polarization of the electrons tunneling from a gold electrode through BM O is analyzed with a counter-electrode of the half-metallic oxide $La_{2=3}Sr_{1=3}M$ nO₃ (LSM O). At 3 K we nd a 50% change of the tunnel resistances according to whether the magnetizations of BM O and LSM O are parallel or opposite. This e ect corresponds to a spin litering e ciency of up to 22%. Our results thus show the potential of com plex ferror agnetic insulating oxides for spin litering and injection.

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Obtaining highly spin-polarized electron tunnelling is an important challenge in now adays spintronics, either for spin injection into sem iconductors [1, 2] or magneto resistive e ects [3]. The classical way is by tunnelling from a ferrom agnetic conductor through a non-m agnetic barrier. This is the basic mechanism of the tunnelling m agnetoresistance (TMR) of tunnel junctions com posed oftwo ferrom agnetic electrodes (spin em itter and spin analyzer) separated by a nonmagnetic insulator [4]. Such tunnel junctions are currently applied to the developm ent of sensors and m em ories (MRAM). Spin polarized tunnelling from a ferrom agnetic metal through a nonm agnetic layer is also what can be used for spin in jection into a sem iconductor [5]. A nother way for spin polarized tunnelling has been little explored: this is tunnelling from a non-magnetic electrode through a ferrom agnetic insulator. The concept was introduced by M oodera et al [6] with EuS tunnel barriers. The e ective barrier height of an insulating layer corresponds to the energy di erence between the Ferm i level and the bottom of the conduction band (or the top of the valence band). A spin dependent barrier height is therefore expected from the spin splitting of the energy bands in a ferrom agnetic insulator. The exponential dependence of the tunnelling on the barrier height can lead to a very e cient spin

Itering. This has been con med, at least at low temperature, by the very high spin polarizations obtained by tunnelling through barriers of EuS and EuSe [6, 7] and more recently with EuO [8]. Spin Itering tunnelbarriers can be of high interest for spin injection into sem iconductors without using ferrom agnetic metals as spin polarized injectors. Very large magnetoresistance e ects can also be expected by switching from parallel to antiparallel the magnetic con guration of two spin Iterbarriers in a double junction [9].

To demonstrate spin Itering by a ferrom agnetic barrier, the spin polarization of the current tunnelling from a nonm agnetic electrode can be analyzed either with a superconductor [6, 7], or with a ferrom agnetic counterelectrode [10]. In the latter case, the ferrom agnetic counter-electrode collects di erently the spins parallel and antiparallel to its m agnetization, so that the current depends on the relative orientations of the m agnetic m om ents of the ferrom agnetic barrier and counter-electrode. This is illustrated by the experiments of LeC lair et al [10] with an Alelectrode, an EuS barrier and a counterelectrode of ferrom agnetic G d. A TM R of up to 130 % at 2K has been obtained with this type of tunnel junction [10].

Up to now, the only experiments of spin Itering by ferrom agnetic barriers have been performed with insulating layers of Eu chalcogenides. However, the very low Curie temperature of EuS (16 K) or EuSe (4.6 K), and the poor chemical compatibility of the Eu chalcogenides with m any possible electrode materials limit their practical potential for spin Itering. The list of other possible candidates includes a few ferrom agnetic perovskite oxides and a large family of ferrites (spinels and gamets). Compared to the complex crystal structure of the ferrites, perovskites are relatively simple and more convenient for integration into tunnel heterostructures, particularly if an isostructural fully polarized half-metallic ferrom agnetic metal, such as $La_{2=3}Sr_{1=3}M nO_3$ (LSMO) [11] is used as a spin analyzer to probe the Iter e ciency.

 $B M nO_3$ (BMO) is an insulating and ferrom agnetic perovskite oxide, having a Curie temperature (T_C) of 105 K and a magnetic moment of 3.6 $_B$ /formula unit (in bulk) [12]. It is a highly insulating compound and, remarkably, the insulating state is very robust [12]. Experimental determinations of the exchange splitting of the (empty) conduction band of BMO have not been reported; how ever it can be estim ated to about 0.5 eV from linear spin-density approximation (LSDA) calculations [13] and to 1.6 eV from LSDA+U [14]. In both cases, the gap is smaller for spin-up electrons, so that when used as a spin Iter barrier, a BMO layer should Iter out spindown electrons and produce a positively spin-polarized current. From the gap found by LSDA+U, a com putation technique which is commonly accepted to be more reliable to calculate band gaps, it follows that the exchange splitting in BMO is larger than that predicted for EuS (0.36 eV [15]) and EuO (0.6 eV [16]), which should result in an increased spin-ltering e ciency. Therefore, both from the electronic point of view and from materials perspective, BMO appears as an ideal perovskite to be implemented as a spin-lter barrier.

In this Letter we report on the grow th of thin epitaxial layers of the B M nO $_3$ perovskite and their integration in spin-liter structures. We demonstrate the spin-litering properties of tunnel barriers of BM O in Au-BM O -LSM O junctions. The device can be operated up to about 40K. O ur results demonstrate the potential of com plex ferrom agnetic oxides for high tem perature spin litering and spin injection.

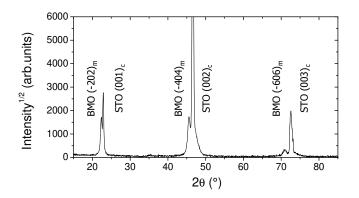


FIG.1: -2 scan of a 30 nm lm grown at 625 C.

BMO thin lm s were prepared on (001) SrT iO₃ substrates by pulsed laser deposition using a K rF excine er laser (=248nm). The growth of BMO was carried out from a non-stoichiom etric multiphase target with a B iM n ratio of 1.15, in an oxygen pressure of 0.1 m bar. B ulk BMO has a heavily distorted perovskite structure that can be represented in the monoclinic C2 space group [17]. In the triclinic pseudo-cubic unit cell the lattice param eters are a = c = 3.985 A, b = 3.989 A with = = 91.4, = 91 [17]. Extensive details on lm growth and structural characterization will be reported elsewhere [18]. Here we just mention that single-phase BMO lm s have only been obtained in a narrow temperature window around 625 C.

In gure 1 we show a -2 scan of a BMO Im of nom inalthickness 30 nm. Di raction peaks occurring at slightly lower angles than the (001)_c re ections (c : pseudocubic representation) of the STO substrate are clearly visible and could be indexed as $(010)_c$ re ections of the BMO lm. They correspond to $(101)_n$ in the monoclinic (m) system. We do not detect (111)_m and (3111)_m re ections, as found by M oreira dos Santos et al [19]. -scans of the (111)_c re ections of the BMO layer and STO substrate (not shown) indicate a cube-on-cube grow th. The out-of-plane parameter (c) deduced from the angular position of the (040)_c re ection is 3.96A, close to the b parameter in bulk (3.989A). As c is inferior to the bulk parameter in spite of the compressive strain induced by m ism atch of -0.7% with the substrate, the reduction of

the cell volum e with respect to bulk is likely to be due

to some Bide ciency. On gure 2, we plot the magnetization (M) vs applied magnetic eld (H) for a 30 nm thick BMO lm after subtracting the diam agnetic contribution of the STO substrate. W e observe a clear ferrom agnetic behavior with a coercive eld of 4700 em easured in-plane and out-ofplane, and a remanence of 62 em u/cm^3 with the eld in plane and 29 em u/cm^3 out-of-plane. The shape of the m agnetization loops indicates that the easy axis clearly lies in the Implane while the out-of-plane direction is a hard axis. The magnetization is not saturated even in a eld of several teslas. It reached only reaching 280 em u.cm 3 at 5T, and is thus fairly reduced with respect to the bulk [12] (M (5T) ' 0.52 M _{S bulk}), which is consistent with the results of Ohshim a et al [20]. The slow increase of the magnetization at high eld is likely to result from the progressive realignment of canted spins. Both the low magnetization and this canted behavior could be explained by the presence of Bivacancies which locally disturb the complex orbital ordering essential for the long-range ferrom agnetic order in BMO [21]. The tem perature dependence of the magnetization of this 30 Im (see inset of Figure 2) indicates that the ferronm m agnetic transition occurs in the vicinity of 97K, which is close to the bulk value (105K).

We have measured the temperature dependence of the resistivity of a 30 nm BMO $\,$ lm in the 150–300K range and found a them ally activated behavior with a room-temperature resistivity of $_{300K}$ = 175 cm ($_{300K}$ = 20 k cm for bulk [12]) and an activation energy of E_a = 239 m eV (E_a = 262 m eV for bulk [12]). Below 150K, the $\,$ lm resistance was exceedingly large to be measured with the available experimental set up. U sing the room – temperature resistivity around T $_{\rm C}$ to about 5G cm. This value, somewhat smaller than that of bulk BMO $_{\rm S}$ ram ics but similar to what is reported for B $i_{0:9}$ Sr_{0:1}M nO $_{3}$ [12], is large enough for the BMO $\,$ lm to be taken as a good insulator.

In order to probe the potential of BM O as a ferror agnetic barrier for spin ltering, ultrathin BM O lm s (3.5 nm) were grown onto a STO (1nm)/LSM O (25nm)//STO

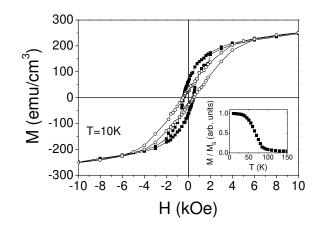


FIG. 2: M agnetization hysteresis cycles measured at 10K with the eld applied in-plane (solid symbols) and out-ofplane (open symbols). Inset : tem perature dependence of the magnetization measured in a eld of 1 kO e.

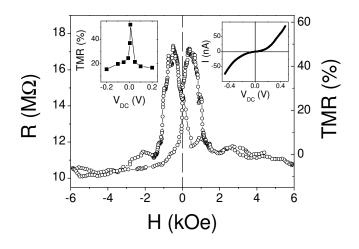


FIG.3: Field dependence of the resistance of a junction at 3K ($V_{DC} = 10 \text{ mV}$). Insets : bias dependence of the TMR (left); I(V) curve of the junction (right).

tem plate. The intercalated 1 nm of STO layer is to m agnetically decouple the BM O barrier from the LSM O electrode. One also knows that the half-m etallic character of LSM O is conserved at the interface with STO [11, 22]. A tom ic force m icroscopy (AFM) in ages of this structure show a very sm ooth surface suitable for patterning the sam ple into tunnel junctions with the follow ing structure: Au/BM O/STO/LSM O.

Sm all junctions (50nm x 50nm) were patterned by a nanolithography process based on the indentation of thin resist by conductive-tip AFM followed by the lling of the resulting hole with a sputtered Au layer [23]. In these experiments, the resistance of the LSM O bottom electrode was always sm all enough to ensure hom ogeneous current ow through the junction. The I(V) curve of the right inset in gure 3 exhibits clearly the non-linear and asymmetric behavior expected for tunnel junctions with

di erent electrodes.

The R (H) plot of a Au/BM O/STO/LSM O junction in Fig. 3 is typical of TM R curves with a TM R of about 50%. The sharp increase of resistance at small eld corresponds to the magnetic reversal of LSM O at its coercive eld of about 100 O e. The resistance drops back to its low-level value above 1.5 kO e, which is close to the value at which the magnetization cycle of the 30 nm BM O In closes (see gure 2). The resistance maximum corresponds to the antiparallel con guration of the magnetization of LSM O with the remanence of BM O (25% of saturation). The slow and alm ost linear resistance variation at elds above 2kO e is expected from the higheld susceptibility observed in the M (H) cycles (see gure

2). A part of this variation m ight also be due to reorientation of canted spins at the LSM 0/ST0 interface [22].

The positive value of the TMR is in agreement with the calculated band structure of BMO [13, 14]. Using an extension of the Julliere model [3] (TMR = $2P_1P_2/(1-P_1P_2)$, where $P_1 = 90$ % is the typical spin-polarization of LSMO at the interface with STO [22] and P_2 the spin-polarization due to the BMO spin litere ect), the measured TMR = 50% corresponds to a spin-liter polarization of 22%. How ever, as the magnetization of the BMO lm at the reversal eld of LSMO is only 25% of its saturation value, we can renorm alize the spin-liter polarization to 88%. This value is close to the maximum spin-liter polarization found for EuS (85%) [6], but still lower than expected from the calculated value of the exchange splitting.

As shown in the inset (left) of gure 3, the TMR decreases at increasing bias. This feature is common in M T Js [24] and ascribed in large part to m agnon excitations at the electrode-barrier interfaces [25]. Thism echanism is certainly also active here on the LSM O interface, but, since only one of the electrodes is magnetic, it cannot account for an approximately equal drop in positive and negative bias. A symmetric drop can only be due to magnon excitations inside the BMO barrier. With a tunnelling current predom inantly carried by electrons having a complex m om entum com ponent perpendicular to the layers and zero parallel component, excitations of magnons of parallel momentum can ip the spin of these electrons and scatter them into evanescent waves of di erent decay length. This can a ect strongly the conductance and the TMR.Although this magnon contribution to the bias dependence of the TMR should be more important in spin Iters than in conventional MTJs, they have not been incorporated in the existing spin 1ter models [26], and certainly deserves the attention of theorists.

In gure 4 we plot R (H) curves obtained for another Au/BMO/STO/LSMO junction at di erent temperatures. At 3K, its resistance is som ewhat lower than that of the junction of Fig. 3, which m ight be due to a slightly lower barrier thickness. The TMR of this junction is

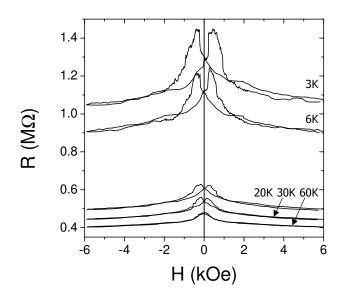


FIG.4: Field dependence of the resistance at di erent tem – peratures for a second junction (V $_{\rm D\ C}$ = 10 m V).

29% at 3K and then gradually decreases at increasing temperature. Beyond 40K, it remains only a small and reversible variation that should be predom inantly due to spin canting reorientation. The temperature at which the spin-litere ect vanishes is thus lower than the Curie temperature of our 30 nm BMO lm s (see inset of gure 2). This may indicate that the T_c of BMO ultrathin layers is depressed compared to bulk value. It is also possible that when temperature increases, the magnetization of the BMO barrier becomes increasingly coupled to that of the LSMO electrode, so that an antiparallel con guration can no longer be obtained. Further work is required to clarify this point.

In summary, we have grown single-phased thin lms of the ferrom agnetic insulator B iM nO₃ on (001)-oriented $SrTiO_3$ substrates. Spin Itering by a BMO tunnel barrier has been demonstrated by magneto-transport m easurem ents on Au-BMO-LSMO junctions which have shown up to 50% of TMR. The TMR decreases rapidly and sym m etrically as a function of the bias voltage, which can be the signature of magnon excitations inside the magnetic barrier. This new inelastic scattering mechanism was not included in the theory of spin lter junctions [26] and has to be studied in more detail. Our results suggest that BM O could be used for spin-injection into sem iconductors as high-quality perovskite/Si [27] and perovskite/G aAs [28] structures have already been fabricated. Further work is needed to fully understand and improve the magnetic properties of BMO ultrathin

In but this is the rst experimental evidence of spin

Itering with a complex oxide and thus constitutes a hallmark towards spin- Iters operating at room temperature, using spinel ferrites for instance. In addition, since BM O is also ferroelectric [29] and as a coupling between the magnetic and dielectric properties in this material has been recently reported [30], our experiment can be thought as a preliminary stage in the exploitation of multiferroic materials in spintronics devices.

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